Attorney's Docket No.: 07977/226002/US354801

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Hisashi Ohtani

Art Unit: 1765

Serial No.: 09/596,755

Examiner: Robert Kunemund

Filed

Confirmation No.: 3261

: June 15, 2000 "

Title

: MANUFACTURING METHOD OF SEMICONDUCTOR AND

MANUFACTURING METHOD OF SEMICONDUCTOR DEVICES

Commissioner for Patents Washington, D.C. 20231

## RESPONSE

HOUR WOOD TO In response to the official action mailed 05/06/02, no. 14 in the above referenced case, please amend the application as follows:

## In the claims:

Please amend claims 2, 4, 8, 10, 14, 16, 20, 22, 25, 29, 30, 32, 36, 37, 41, and 42 as follows:

2. (Amended) A method for manufacturing a semiconductor device comprising steps of:

forming a semiconductor film comprising silicon over a substrate; and

irradiating said semiconductor film by scanning with at least first and second pairs of linear infrared lights in a predetermined direction, intensities of the second pair of

## CERTIFICATE OF TRANSMISSION BY FACSIMILE

I hereby certify that this correspondence is being transmitted by facsimile to the Patent and Trademark Office on the date indicated below.

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